

ABSTRACT



162162

POLISHING COMPOSITION AND POLISHING METHOD

- 5 A polishing composition contains alumina, a complexing agent, and an oxidizing agent. It is preferable that the complexing agent is at least one compound selected from an α -amino acid, ammonia, and an ammonium salt. The polishing composition is preferably used in applications for polishing
- 10 an object having a resin section with a trench, and a conductor layer provided on the resin section so that at least the trench is filled with the conductor layer.

Fig. 1



G00002